

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	((substrate or wafer) and (pattern\$4 or reticle or mask) and (chamber or hous\$4 or cas\$4) near3 (condition\$4 or control\$4) and (determin\$4 or detect\$4 or measur\$4 or sens\$4) near4 (mark or point or contour or notch) near5 (carrier or arm or robot or ((transfer\$4 or transport\$4) adj3 (device or system or element or stage or member))))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/07 15:54